



NOV 23 2005

Attorney's Docket No.: 042390.P16676

Patent

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Steven Keating

Examiner: Dang, Trung Q

Application No.: 10/750,054

Art Unit: 2823

Filed: December 30, 2003

For: an amorphous etch stop for the
anisotropic etching of substrates

Mail Stop RCE
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT
ACCOMPANYING REQUEST FOR CONTINUED EXAMINATION (RCE)

Dear Sir:

In response to the Final Office Action mailed on September 19, 2005, please enter the following amendments and reconsider the present application in view of the remarks below, in connection with the accompanying Request for Continued Examination (RCE).

First-Class Certificate of Mailing

I hereby certify that this correspondence is being deposited with the United States Postal Service as first-class mail with sufficient postage in an envelope addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia, 22313-1450 on

November 21, 2005

Date of Deposit

Dianne Neathery

Name of Person Mailing Correspondence

Dianne Neathery
Signature

November 21, 2005

Date

Inventor: Steven Keating
Application No.: 10/750,054

Examiner: Dang, Trung Q
Art Unit: 2823